

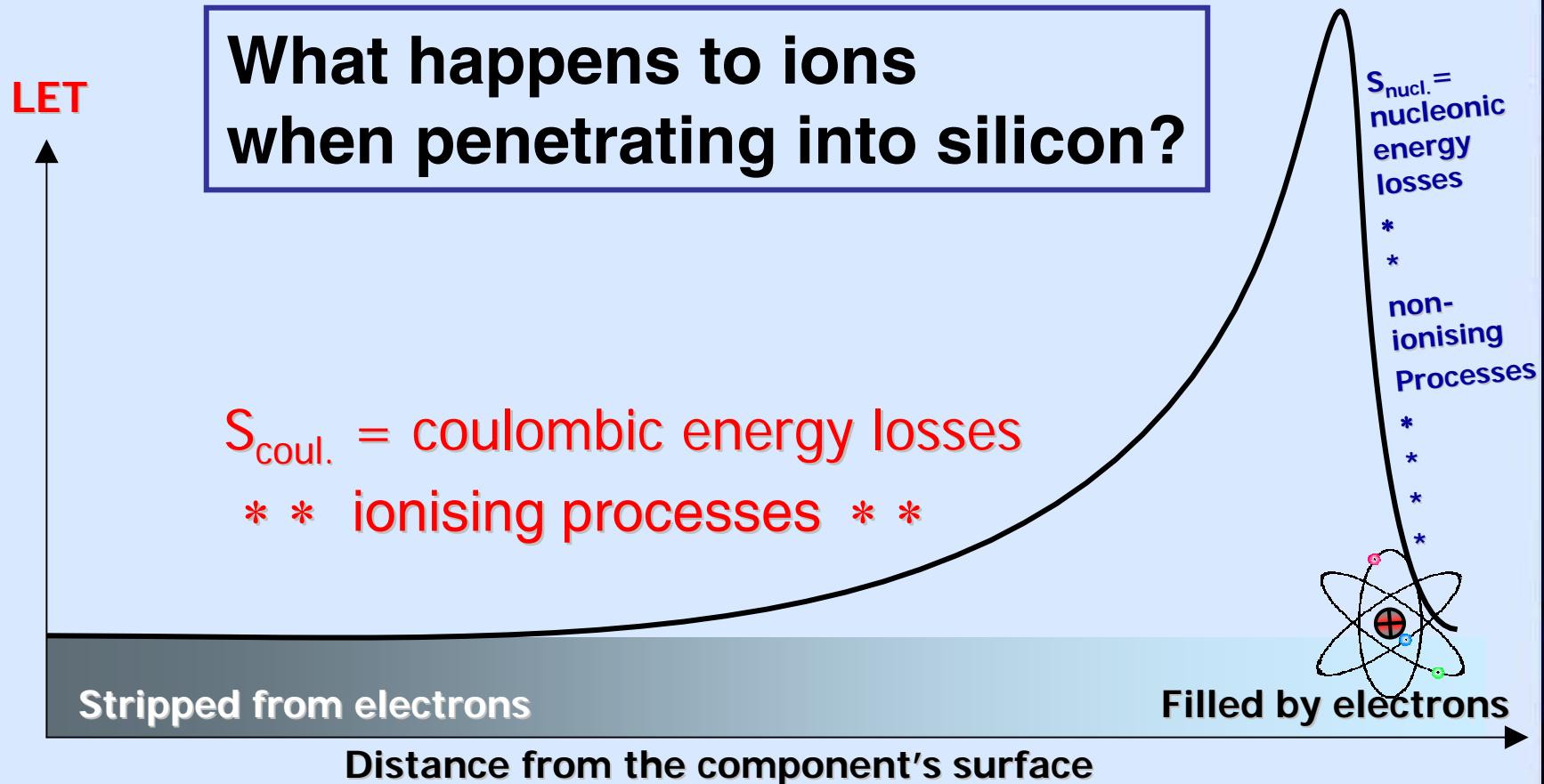
Linear Energy Transfer of Heavy Ions in Silicon

by

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What happens to ions when penetrating into silicon?



$$S_{\text{stopping power}} = S_{\text{coul.}} + S_{\text{nucl.}} \approx \text{LET} + \text{NIEL}$$

Described by semi-empirical codes based on Bethe-Bloch formula

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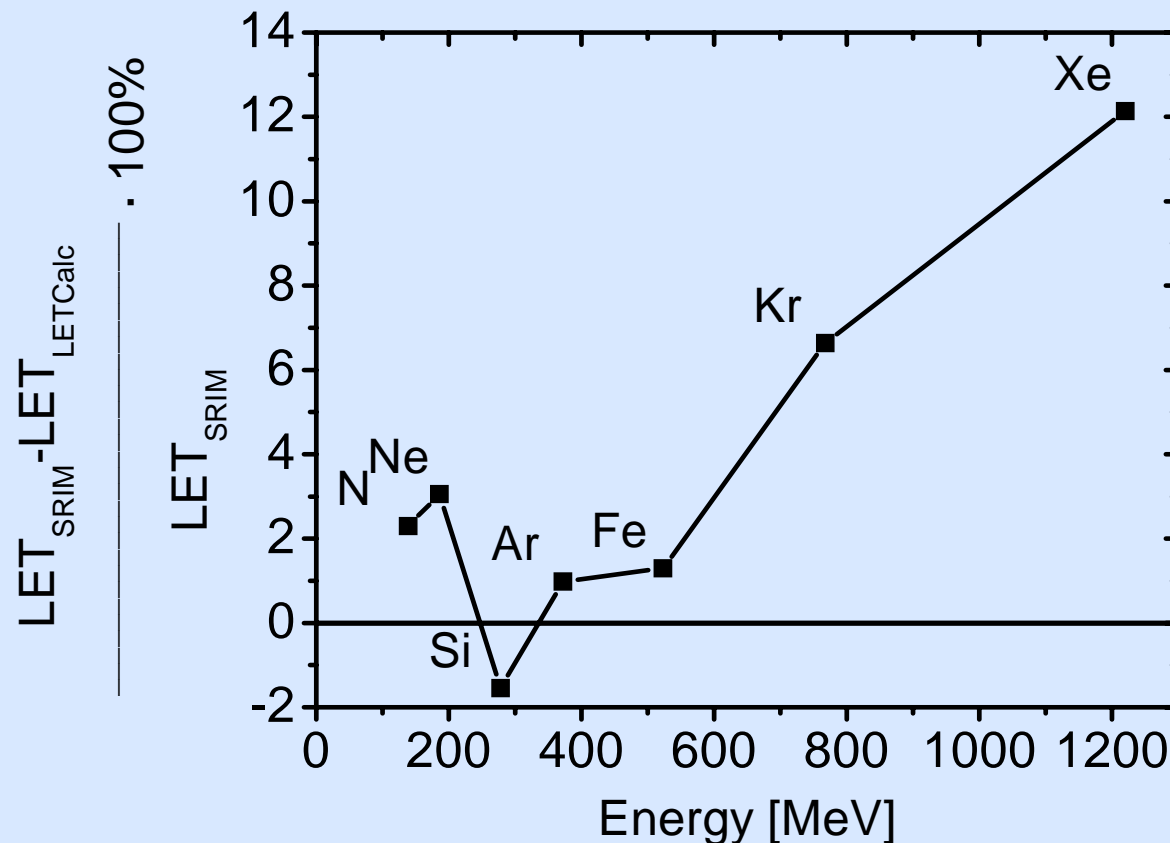
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Different codes give different LET values

For example, the two most commonly used codes are:

SRIM.....The Stopping and Range of Ions in Matter by Ziegler et al., <http://www.srim.org>

LETCalc..LET Calculator developed by Brookhaven National Laboratory, <http://www.tvdg.bnl.gov>



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Break points of the study project

May 2005: The question was picked up in the 1st RADECS Thematic Workshop in Jyväskylä → a workgroup to find ways for harmonising LET and range values in different test laboratories was formed...

September 2005: The group met in RADECS2005, Cap d'Agde, and decided to consult the stopping power experts in Jyväskylä.

Spring 2006: A research proposal was submitted and the experiment carried out in March

September 2006: Results were introduced in RADECS2006, Athens

January 2007: The paper accepted to IEEE-TNS

- *Linear Energy Transfer of Heavy Ions in Silicon*, A. Javanainen*, T. Malkiewicz, J. Perkowski, W. H. Trzaska, A. Virtanen*, G. Berger*, W. Hajdas*, R. Harboe-Sørensen*, H. Kettunen, V. Lyapin, M. Mutterer, A. Pirojenko, I. Riihimäki, T. Sajavaara, G. Tyurin, H. J. Whitlow, *Proc. RADECS2006 Workshop, September 27-29, 2006, Athens, Greece*

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* = workgroup member

Experimental setup



Time-of-flight spectrometer
used to determine energies
with and without target foils



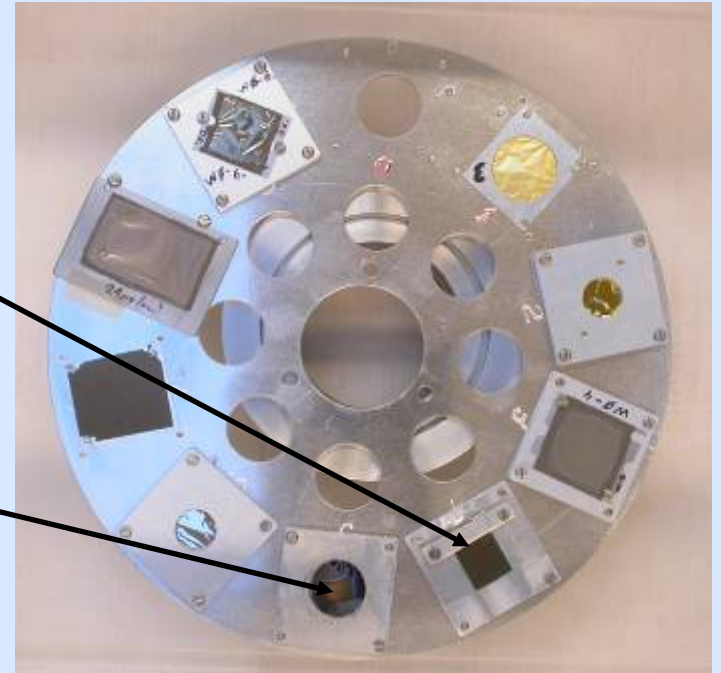
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Targets used

Two silicon foils:

- CHICSi^{*)}-type ΔE -detector with evaporated layers removed:
 $d = (2.92 \pm 0.03)\text{mg/cm}^2 = 12 \mu\text{m}$
- self-supporting sample made by etching from single crystalline Si<110> wafer
 $d = (0.300 \pm .003)\text{mg/cm}^2 = 1.2 \mu\text{m}$

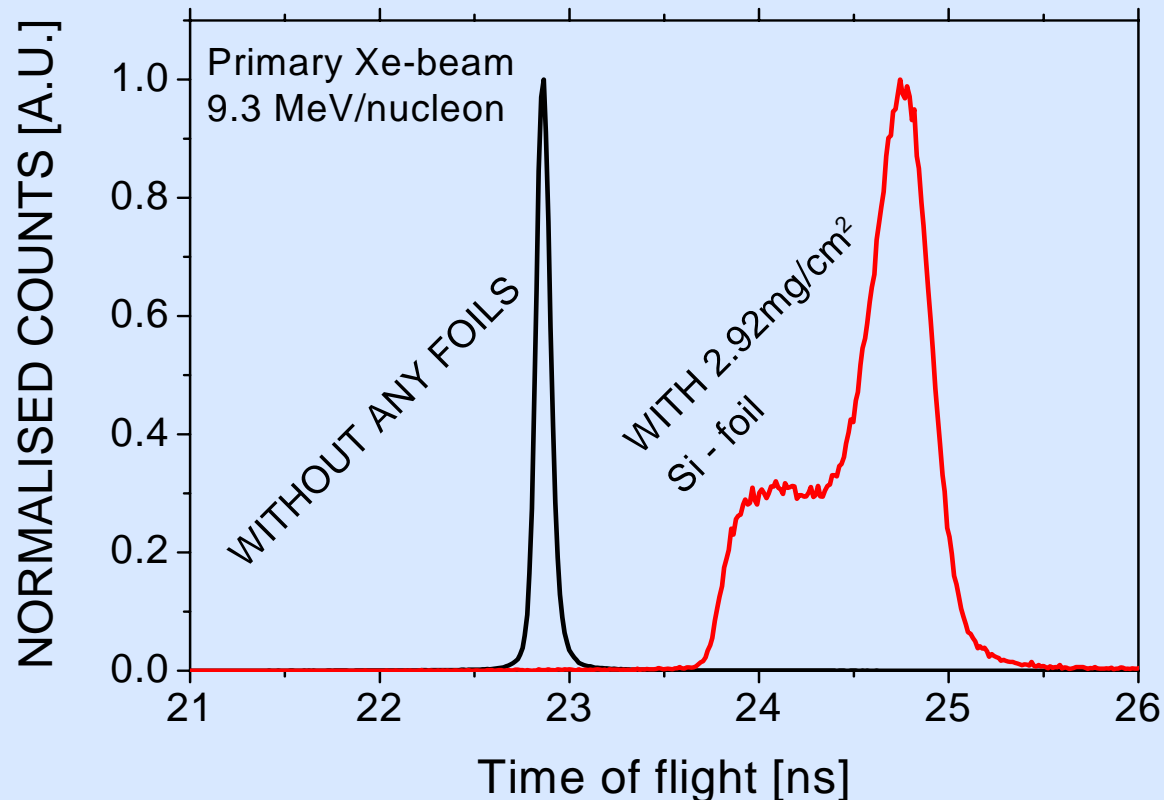
^{*)}CELSIUS Heavy Ion Collaboration Silicon



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Channeling effect

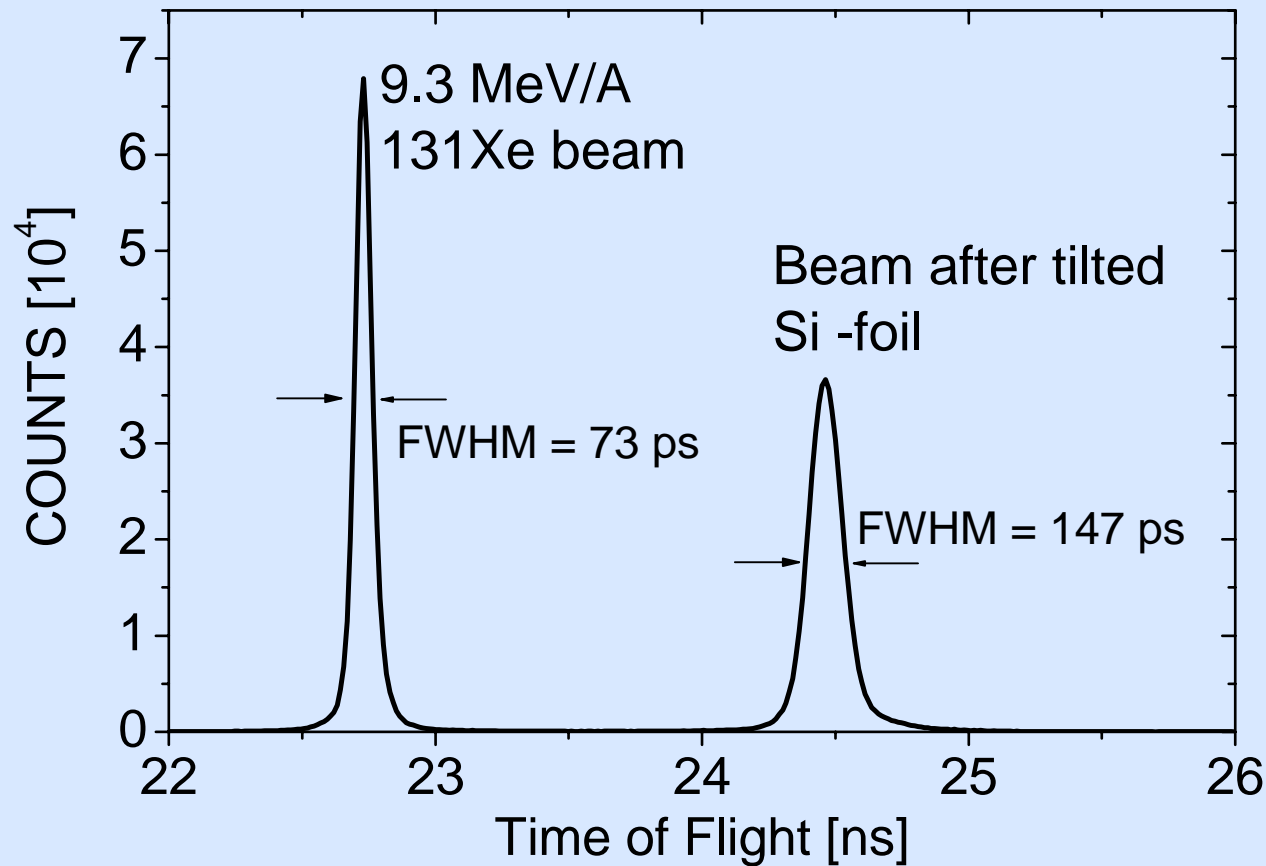
- Strong channeling effect was observed in both samples



- Problem solved by tilting the foils few degrees

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Resolution of the measurement setup

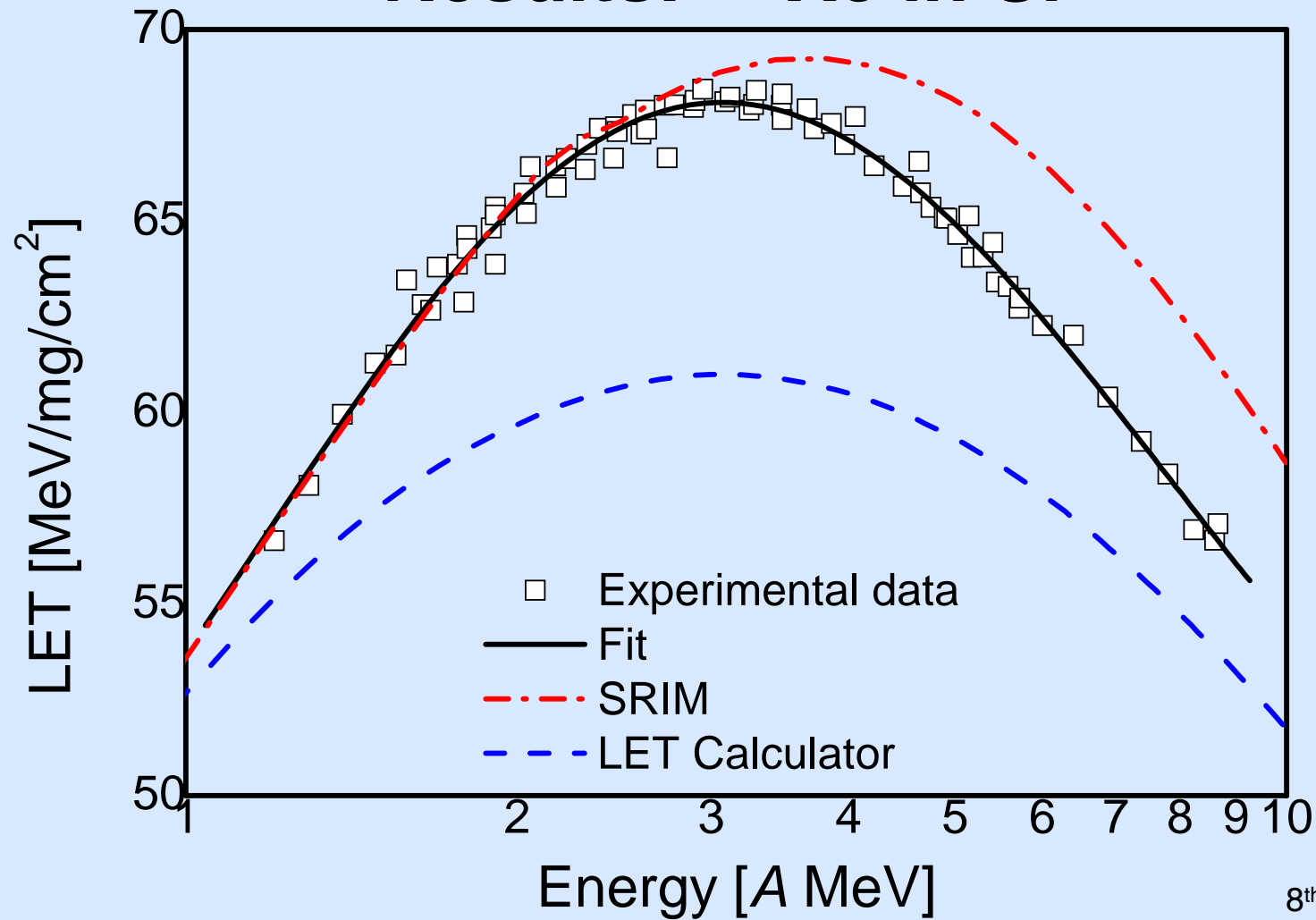


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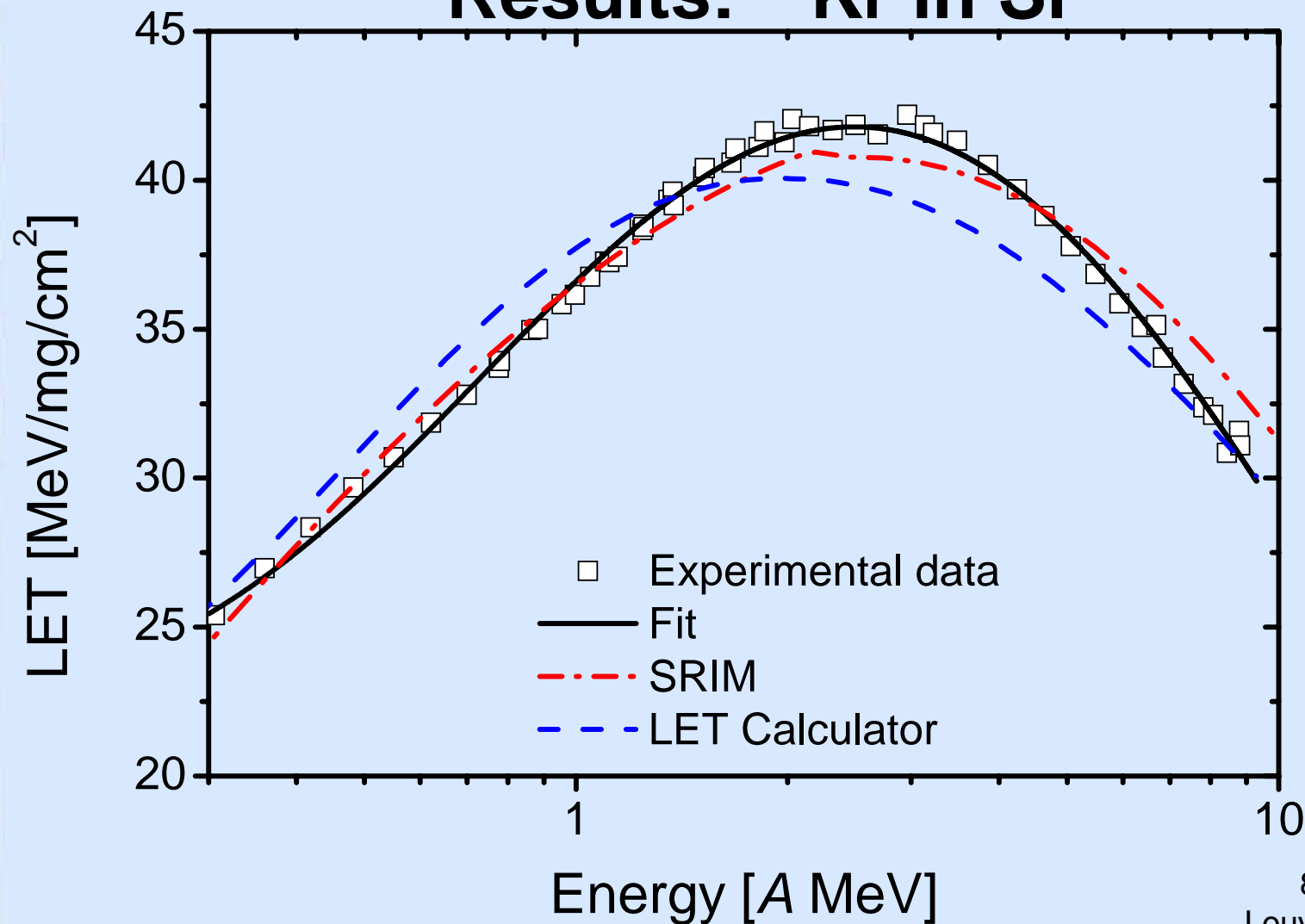
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Results: ^{131}Xe in Si



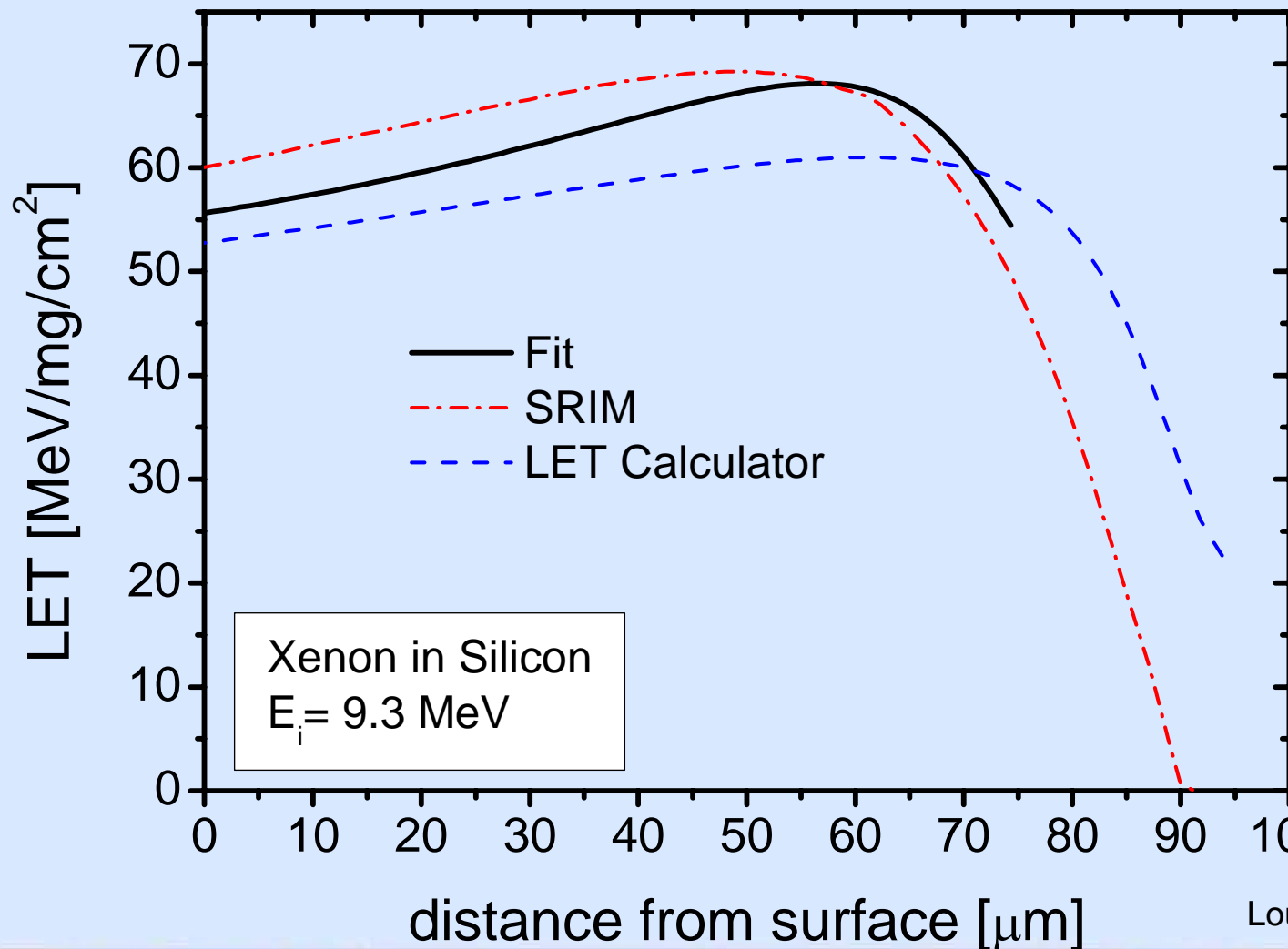
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Results: ^{82}Kr in Si



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LET vs. penetrated distance



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Comments and recommendations

Reviewer 1 Comments:

This paper describes very important subject to the community ... will provide excellent base line towards developing good simulation code for the common LET estimation..., the referee supports the publication of the current draft.

Reviewer 2 Comments:

Your paper is the beginning of an interesting analysis about the ion LET in silicon ICs. The paper shows a significant discrepancy between the predicted LET (simulated with SRIM and the LET Calculator) and your experimental measurements.

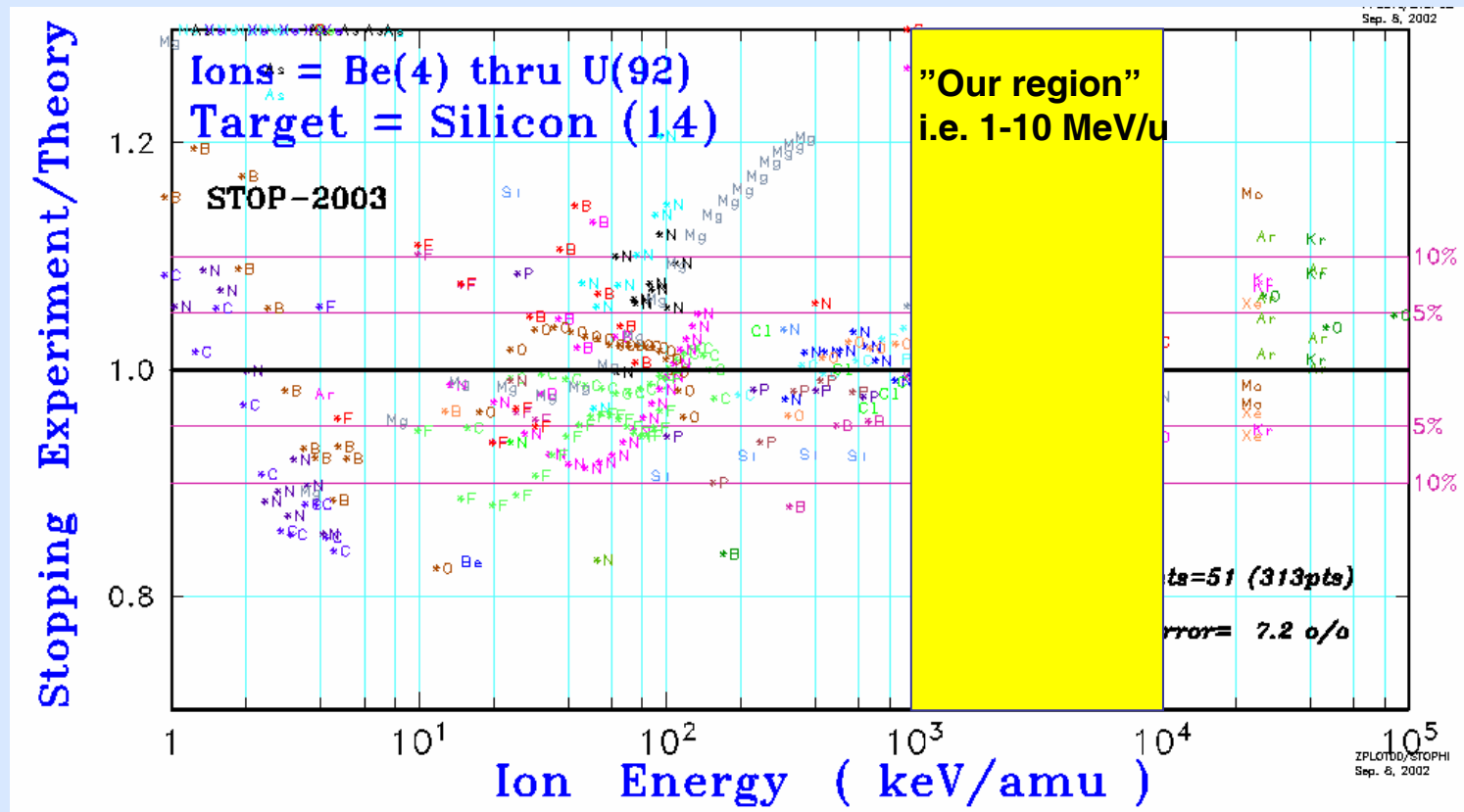
...

MA: **How do you interpret the differences between the simulated results and your experimental data?** What do you think is not correctly modeled in the codes (SRIM, LET Calculator). You only mention the fact that SRIM and LET Calculator assume **an amorphous target** instead of a crystalline structure. It I would like you to develop **does not explain the difference between the two codes themselves**. the interpretation of your observations. This point is important. It will give a real value to your paper.

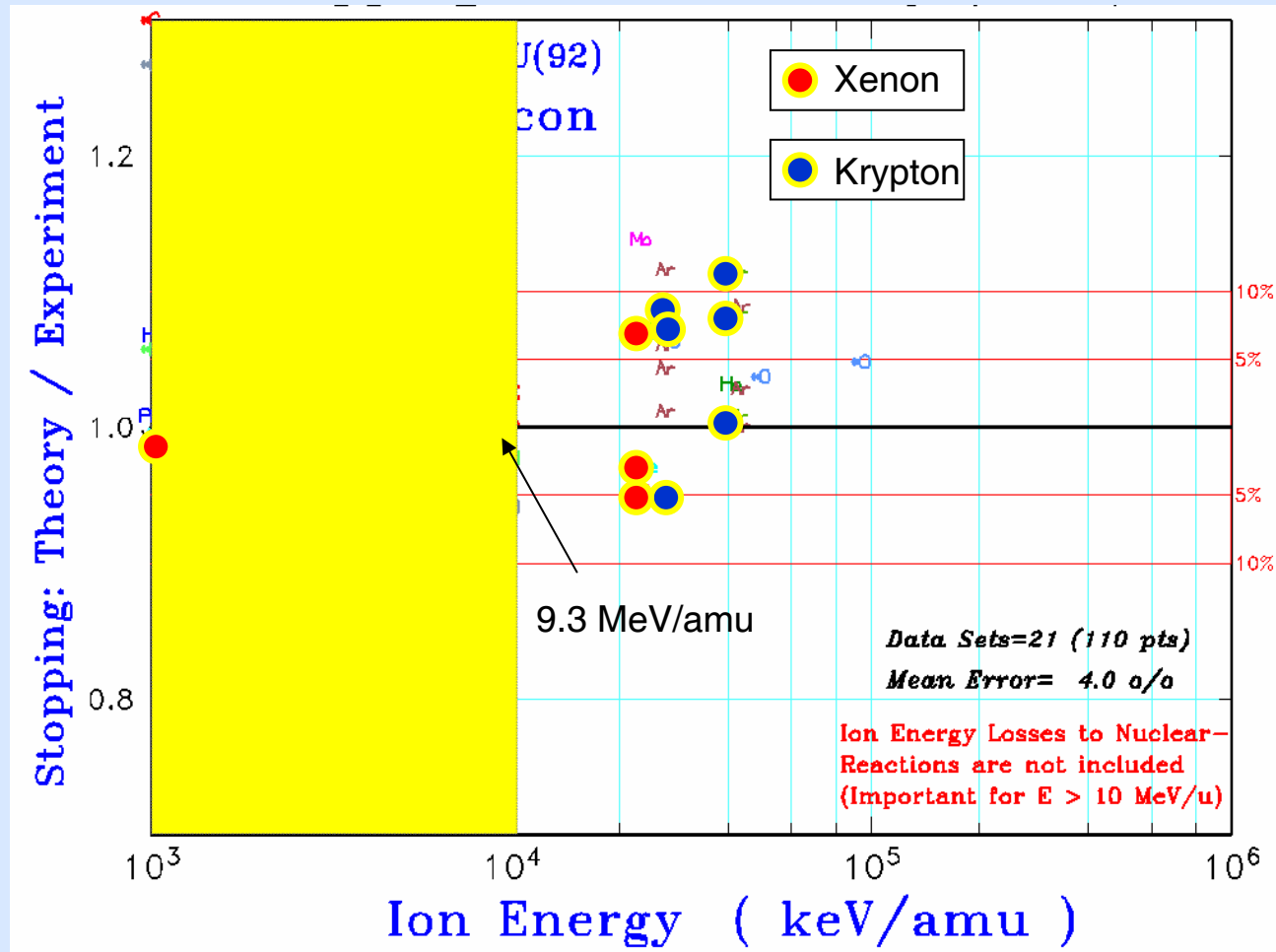
MI: **I suggest that if you have additional results (another ion), it might be good to include them in the paper.**

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SRIM data base for silicon target



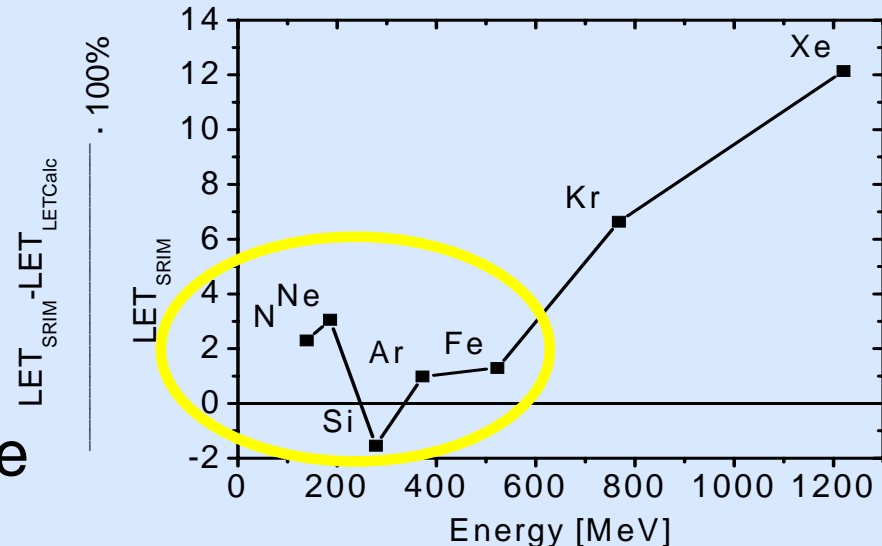
SRIM data base for silicon target



FUTURE ACTIONS?

Still five ions to go

If our data would be implemented in SRIM code, will the accuracy be good enough?



Or is there a need for community's own LET-calculator for the proper energy range ($E > 1$ MeV/u) and ions?

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Conclusions

Experimental LET for Xe and Kr in Si defined at 1-10 MeV/u
–differs from simulated estimates; e.g. Xe 8% for SRIM

Recent simulation tools only "indicative" when $E > 1$ MeV/u
–especially important when irradiating from rear and DUT's exact thickness not known accurately
–more energetic ions would also help this

Community has clear need for more accurate LET and range estimates at proper energy range for certain ions
–whether the recent codes will be improved
–or we make our own LET/range calculator

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THANK YOU FOR YOUR ATTENTION!

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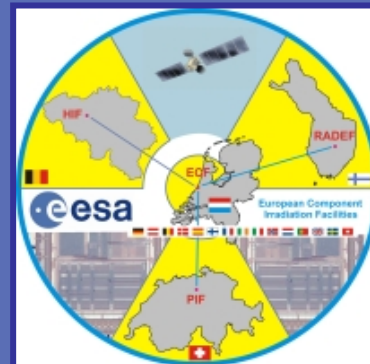
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